



#### WG5: New characterization techniques and facilities of common interest Development of a new tool: Two Photon Absorption - TCT

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The development of new semiconductor characterization techniques is a priority for future detector developments. These techniques should enable high-resolution imaging and defect spectroscopy of semiconductor materials, as well as advanced characterization of charge transport properties.

Two Photon Absorption – TCT is an example of these characterization techniques:

- Benefited from RD50 common fund both during development and measurement campaigns.
- It also received financial support (laser procurement) from CERN Knowledge Transfer fund (2017).

TPA-TCT is now available to the community:

- Used within RD50 and RD42 collaborations.
- Laser is a commercial tool (Si bandgap).
- As a characterization tool, it is transversal to several WGs(1,2,3,4,6,8)
- Expertise in the technique built up by different groups





### Development of TCT as characterization tool DRD3

Study of non-equilibrium charge carriers in semiconductors (TCT=Transient Current Technique) started in the **90's** (Fretwurst, Li, Eremin, Verbitskaya...) [1].

**2009** G. Kramberger et al. develop **edge** laser illumination -> depth profiling added to TCT [2].

**2013** First **T**wo **P**hoton **A**bsorption-TCT measurement in silicon and diamond (IFCA, CERN, UPV, US)





Single Photon-TCT 2D resolution (XY) e-h separation

Single-Photon TCT 2D resolution (ZY) Allows profiling (Q(z), v<sub>drift</sub>(z),...)

Two Photon TCT True 3D resolution

TCT has been/is a workhorse for characterization of detectors for the RD48-RD50 collaborations.

[1] Review: M. Zavrtanik, 2<sup>nd</sup> TCT workshop [2] doi: 10.1109/NSSMIC.2009.5402213.



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### Two Photon Absorption TCT







**SPA-TCT:** 2D resolution

**TPA-TCT:** 

3D resolution along beam propagation direction (Z).





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### RD50 and CERN-KT support

## DRD3

• TPA-TCT developed within RD50. Access to demonstrator fs-laser facility and measurement campaigns supported by RD-50 common fund.



A non-destructive laser application for quality control & radiation studies in semiconductor devices



field profiles within semiconductor devices by non-destructive femtosecond laser induced Two-Photon Absorption. Several fields could benefit from this development, amongst them Quality Control & Assurance of semiconductor devices, E-Field and Charge Collection Efficiency mapping of photosensors, and radiation damage studies for high-energy physics detectors.

This project is a collaboration between CERN and the Instituto de Física de Cantabria (CSIC-UC)

• TPA-TCT laser procurement via **CERN-Knowledge** Transfer contract.





KEY FACTS

CONTACT PERSON



# Customized systems built by the community DRD3



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#### Related Knowledge & Support

**ECFA** 

European Committee for















## System flexibility: beyond bulk studies DRD3

400

350

300

250

- 150

100

- 50

∆t<sup>m</sup>

[deg]



**RD53B: Single Event Effects found during heavy-ion** testing on specific transistors. Used TPA-TCT back side injection to find sensitive elements  $\rightarrow$  Fixed in new version

J. Lalic, S.Pape

**ECFA** 

#### High speed optical links (CERN EP-R&D WP6):

Benchmark of carrier recombination lifetime in Si-waveguides. Inject charge using TPA-TCT  $\rightarrow$  Free carriers absorb light that passes trough the waveguide  $\rightarrow$  Transient behaviour as free carriers recombine:





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## Beyond silicon



TPA-TCT also used to study other materials. It has been demonstrated in **diamond** (RD42) and **SiC** (RD50), using 400 nm fs laser.



**2016:** proof of principle of TPA-TCT in **diamond** with 400 nm TPA at SGIKER (Bilbao). See as well C. Dorfer, <u>https://doi.org/10.1063/1.5090850</u>



**2022:** TPA-TCT in **SiC** with 400 nm TPA at SGIKER (UPV, Bilbao). C.Quintana, <u>41<sup>st</sup> RD50 meeting</u>



## Envisaged improvements/updates DRD3

NA=0.5 w<sub>o</sub>=1 μm

z<sub>R</sub>=7 μm (in Silicon)

#### Hardware-wise

2



FYLA is working in a fully fibered laser, tunable pulse duration: 100-1000 fs

Their goal is to provide a "turn-key" TPA-TCT solution, including mechanics and software.

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Radiation hardness demands thin detectors (  $\leq$  50 µm). Longitudinal resolution in TPA is improved using objectives with NA>0.5 (=TPA baseline).

In thick devices ( > 70  $\mu$ m), very high NA (>0.5) leads to spherical aberration (SA) of the focus, degrading TPA measurement.



This effect can be compensated using Spatial Light Modulators (~25k€).



Timing measurements with TPA can be easily achieved splitting the beam before the objective. An LGAD placed on a monitoring branch can be used as time reference for jitter calculation.



## Envisaged updates

#### Software-wise

#### 0

#### Analysis package:

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- 1) ROOT based (1D, 2D plotting)
- Includes SPA subtraction methods for irradiated detectors



#### 2

#### **TRACS simulation package:**

- 1) For diodes and microstrips
- 2) Fast Poisson solver. It accepts arbitrary illumination patterns

#### B

Online user forum and organization of hands-on workshop on TPA-technique

DRD3



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## Milestones & deliverables (2024-26) DRD3

- Deliverable: reduction of excitation "voxel" dimensions (longitudinal  $\leq$ 3.5 µm in Si)
  - Using high NA objectives and Spatial Light Modulators (~2 years)
  - Extension of TPA setup with timing reference (this year)
- FYLA:

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- Step 1: All fiber laser, tunable pulse length (1 year)
- Step 2: Full TPA-TCT system "turn-key" (~2 years)
- Build-up of user community:
  - Organization of tutorials and hands-on workshops (also within WG8).
  - Online User forum (technical support for hw&sw).